Ferromagnetic topological crystalline insulator Sn_{1-x}Mn_xTe in an inhomogeneous magnetic field



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Introduction / Motivation

Topological crystalline insulators:

- SnTe is an archetypical topological crystalline insulator
- Topological surface states (TSS) are protected by the (110) mirror plane symmetry and has linear (Dirac) dispersion

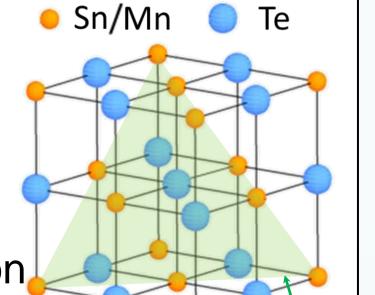
Material: Ternary Sn_{1-x}Mn_xTe:

- □ Transition metal Mn-doped SnTe is a ferromagnet
- RKKY exchange interaction

Motivation

Prediction of the novel emergent

behavior of electrons in a FM semiconductor



- Two important length scales in SC:
- London penetration depth λ
- Superconducting coherence length ξ 2 types of SCs:
 - Type I: $\lambda < \xi/\sqrt{2}$

Superconductor

Insulator

Sn_{1-x}Mn_xTe

• Type II: $\lambda > \xi/\sqrt{2}$

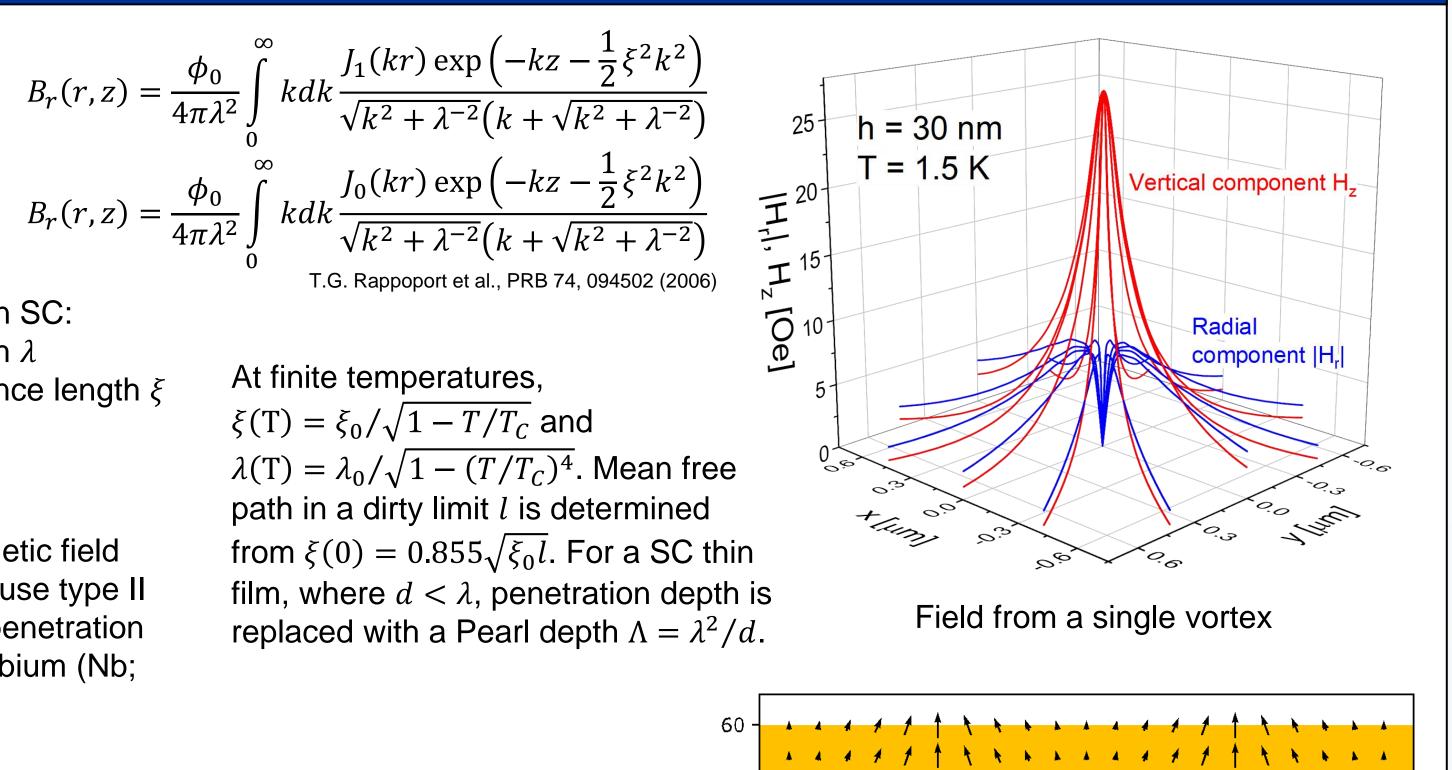
To achieve a significant magnetic field modulation, it is preferable to use type II superconductor with a small penetration depth λ . Optimal choice – Niobium (Nb; $\lambda_0 = 52 \text{ nm}, \xi_0 = 39 \text{ nm}$)

h = 20 nm; T = 1.5 K	h = 50 nm; T = 1.5 K
$H = 10 \Omega e$	

Modelling

At finite temperatures,

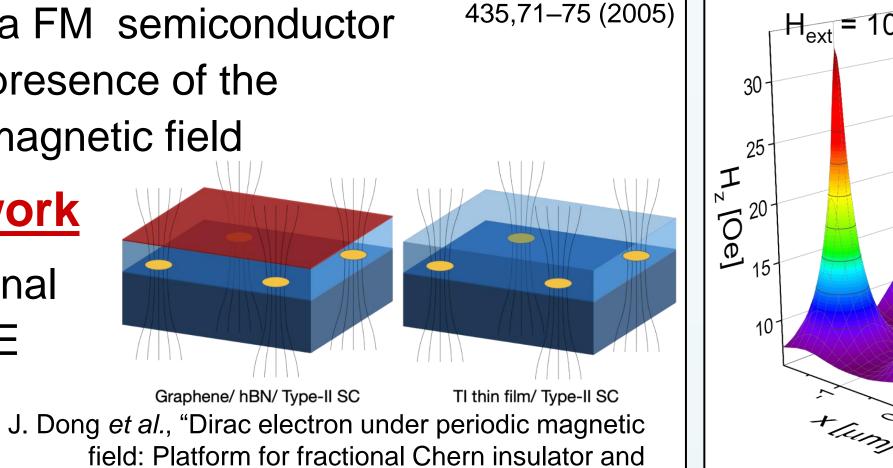
 $\xi(T) = \xi_0 / \sqrt{1 - T / T_c}$ and



or Dirac material in the presence of the periodically modulated magnetic field

Goal of present work

Study effect of the external field modification on AHE behavior of a FM semiconductor (TCI)

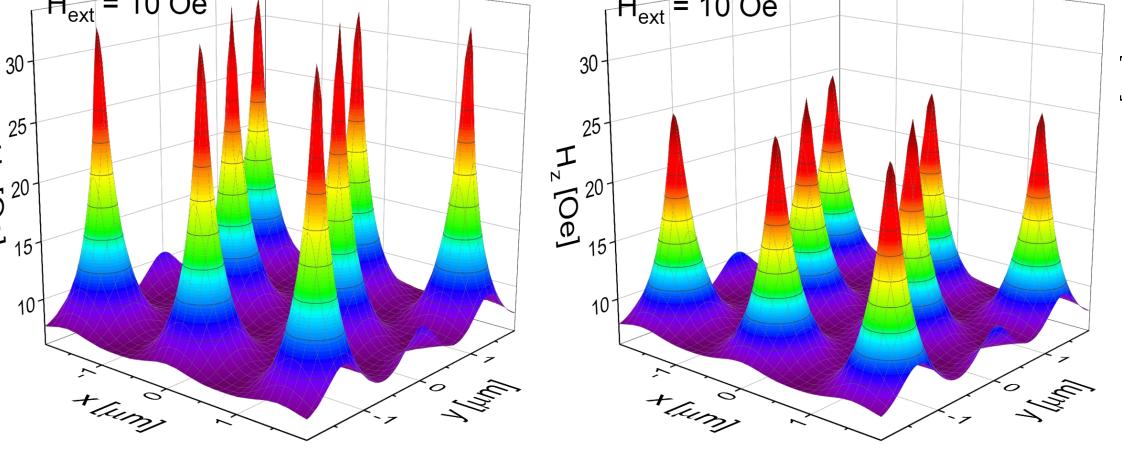


generalized Wigner crystal" arXiv:2208.10516

M. Berciu *et al.*, "Manipulating spin and

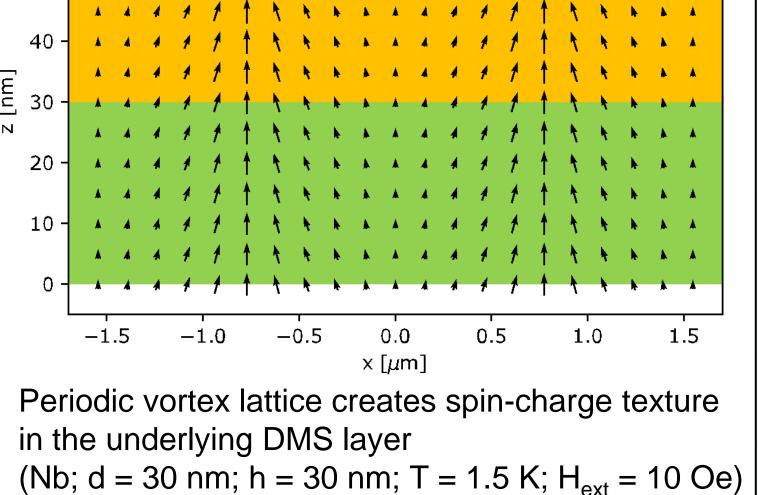
using superconductor vortices" Nature

charge in magnetic semiconductor



 $B_r(r,z) = \frac{\phi_0}{4\pi\lambda^2}$

d



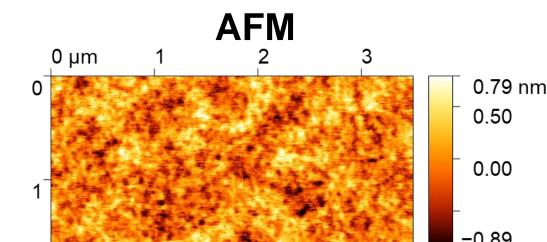
Experimental results

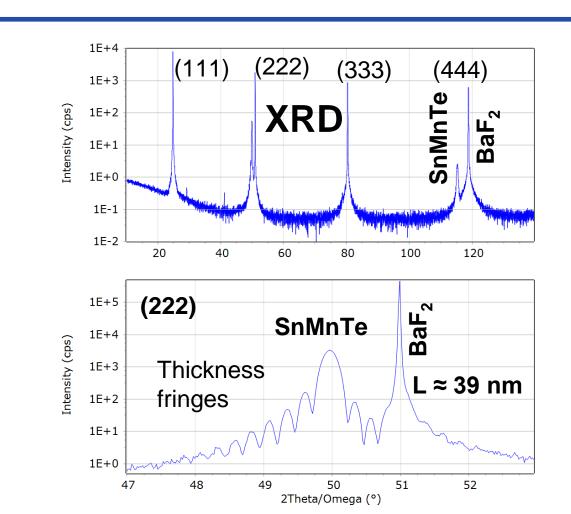
MBE growth

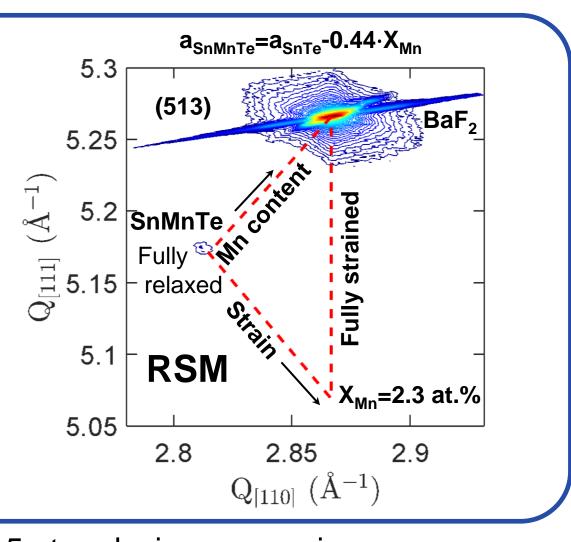
- Veeco GENxplor, SnTe, Mn, Te sources, (111) BaF₂ substrates
- $Sn_{1-x}Mn_xTe$ films, $x_{Mn} = 0 \div 0.07$, 20-50 nm thickness
- RHEED *in-situ*, shows streaky pattern, smooth surface
- AFM confirms atomically smooth surface
- XRD, only (111) orientation, systematic reduction of lattice constant with Mn doping, no strains detected from asymmetric RSM
- Nonstoichiometric growth with high Te flux drastically increases surface roughness, in-plane compressive strains up to -0.5 % introduced

Characterization of the material before the processing

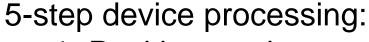


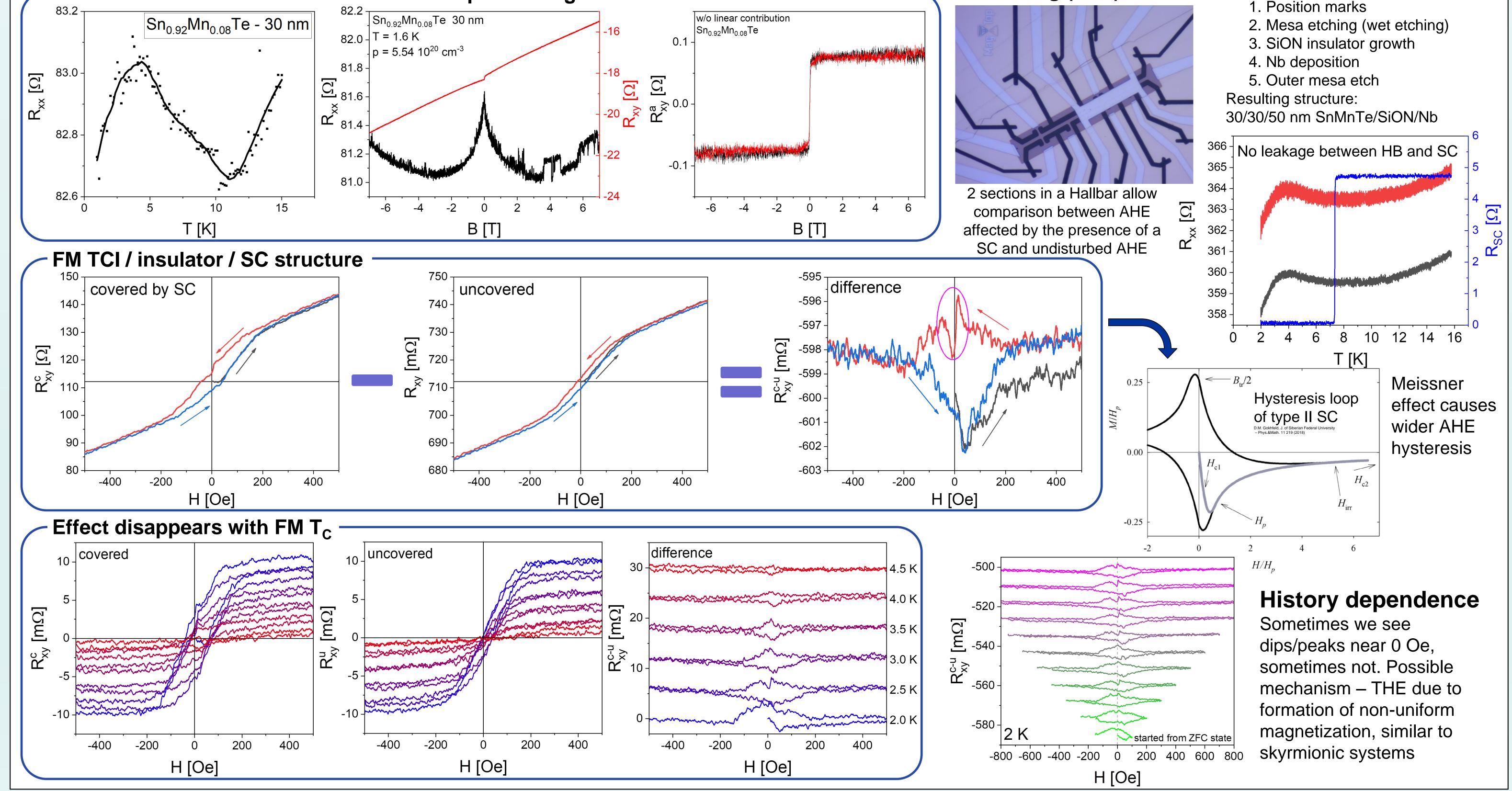






Processing (EBL):





Main results

First attempt to study electron transport in DMS under periodic field modulation created by a SC

Clear effect of the Meissner state on AHE behavior in the DMS layer

Signatures of the vortex lattice effect on the AHE behavior in the DMS layer

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